



UNIVERSITY OF
LIVERPOOL

Charge Collection Efficiency for Planar Silicon Detectors after Doses up to $10^{15} n_{\text{eq}} \text{ cm}^{-2}$

A. Affolder, P. Allport, G. Casse
University of Liverpool

The SLHC Upgrade

- Super-LHC is a factor of $10\times$ luminosity upgrade to the Large Hadron Collider (LHC)

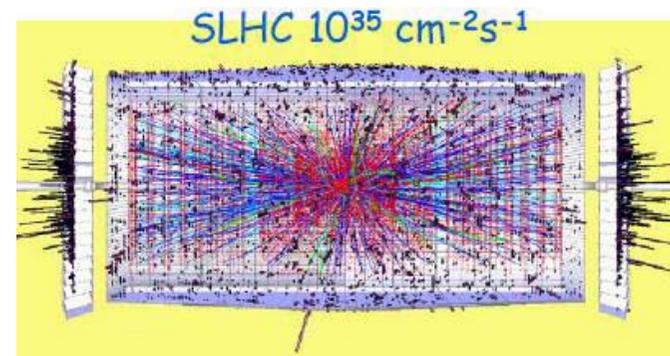
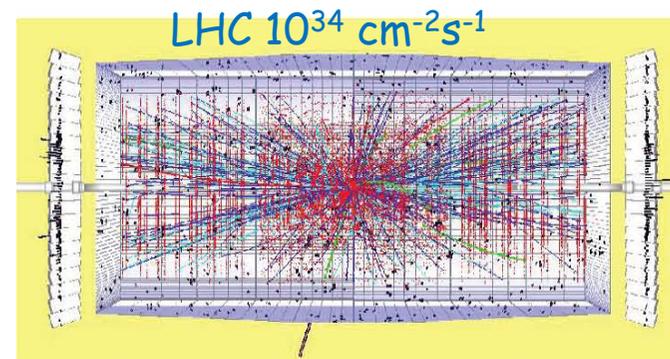
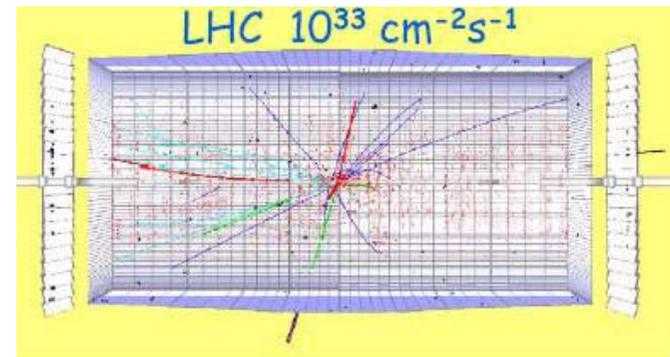
LHC (2008-2015?),
~1 billion collisions per sec
 $\mathcal{L} = 10^{34}\text{cm}^{-2}\text{s}^{-1}$, 10 years, 500 fb^{-1}

Super-LHC (2015?-),
~10 billion collisions per sec
 $\mathcal{L} = 10^{35}\text{cm}^{-2}\text{s}^{-1}$, 5 years, 2500 fb^{-1}

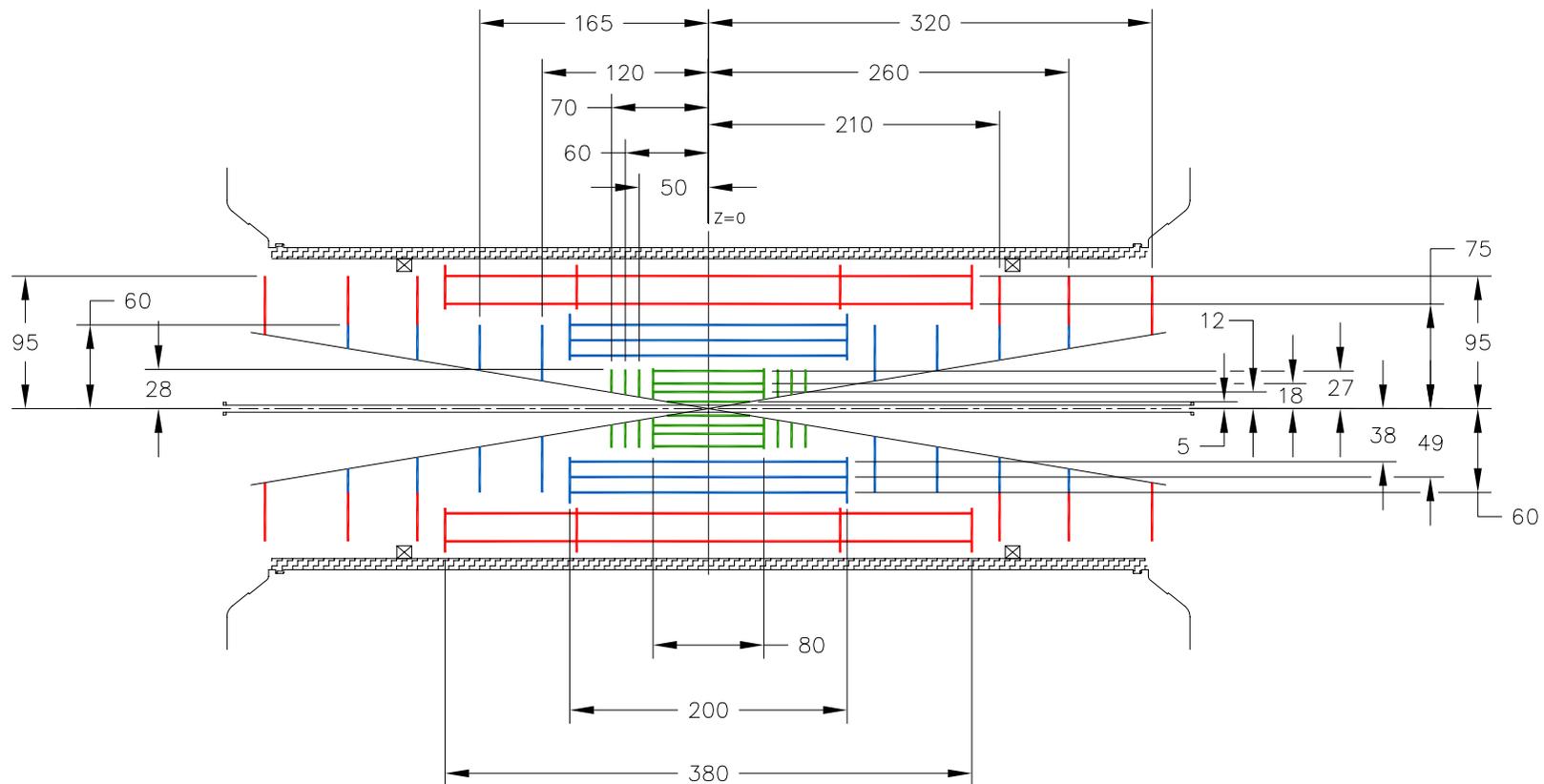
The main challenges to the vertexing and tracking detectors are:

- Charge collection after high radiation doses
- Density of charged particles (Segmentation)
- Thermal management (Runaway)

This talk focuses on charge collection issues for silicon microstrip detectors



ATLAS Upgrade Layout



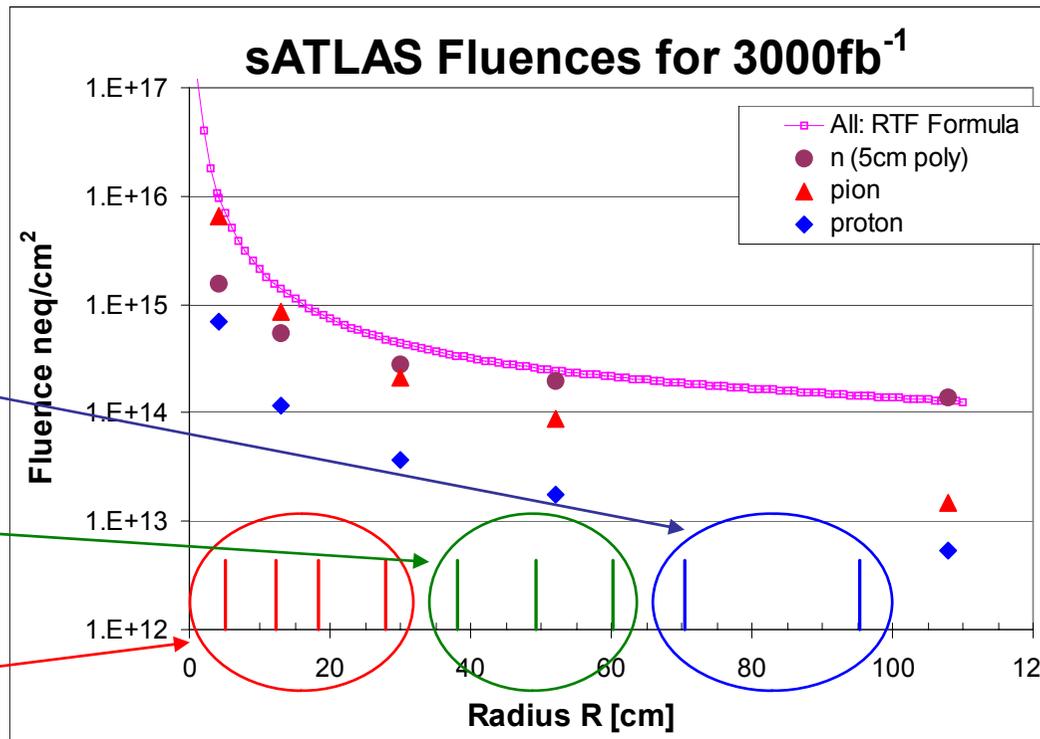
4 Pixel, 3 Short strips, 2 Long strips

100 m² of long strips, 60 m² short strips, at least 5 m² of pixels

BROOKHAVEN
NATIONAL LABORATORY

Fluence in Proposed sATLAS Tracker

Strip length and segmentation determined by occupancy < 2%



Mix of **neutrons**, **protons**, **pions** depending on radius **R**

Long and short strips damage largely due to **neutrons**

Pixels damage due to **neutrons** and **pions**

ATLAS Radiation Taskforce http://atlas.web.cern.ch/Atlas/GROUPS/PHYSICS/RADIATION/RadiationTF_document.html

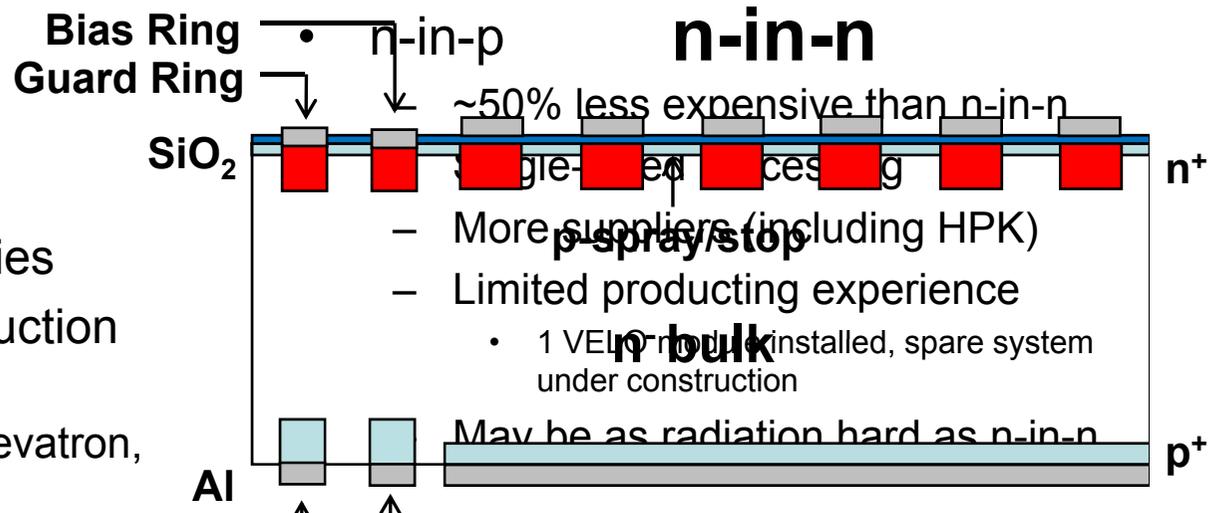
Design fluences for sensors (includes 2x safety factor) :

Innermost Pixel Layer:	$1-1.6 \cdot 10^{16} \text{ n}_{\text{eq}}/\text{cm}^2 = 500 \text{ Mrad}$
Outer Pixel Layers:	$3 \cdot 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2 = 150 \text{ Mrad}$
Short strips:	$1 \cdot 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2 = 50 \text{ Mrad}$
Long strips:	$4 \cdot 10^{14} \text{ n}_{\text{eq}}/\text{cm}^2 = 20 \text{ Mrad}$

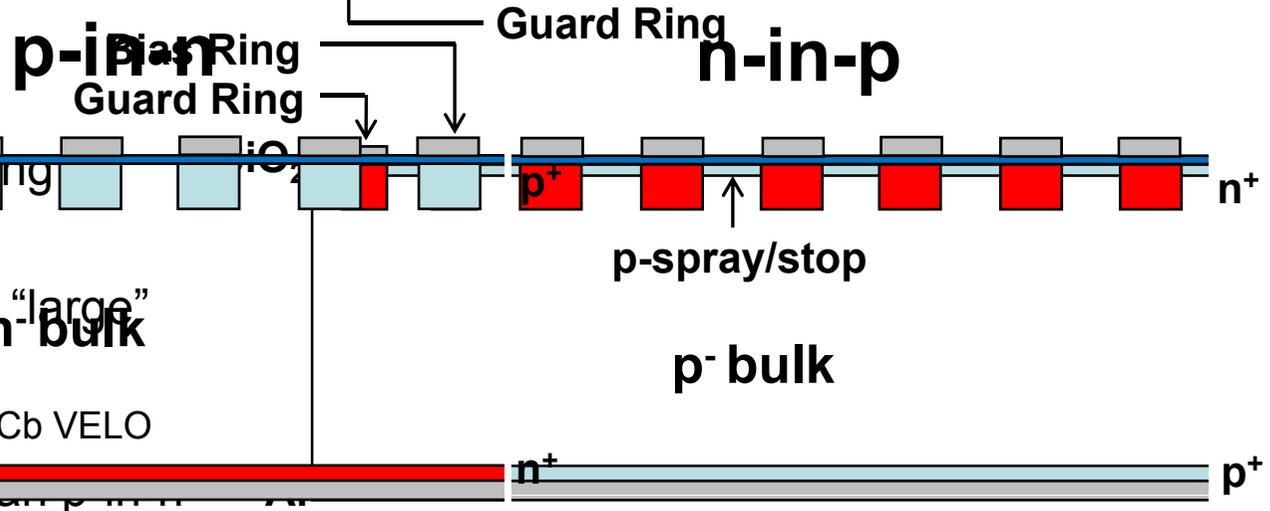
Need to study response to both neutral (neutrons) and charged (proton) particle irradiations

Geometry Choices

- p-in-n
 - Least expensive
 - Single-sided processing
 - Available from all foundries
 - Most experience in production
 - All strips at CMS/ATLAS/ALICE, Tevatron, b-factories, ...



- p-in-n
 - Most expensive
 - Double-sided processing
 - Limited suppliers
 - Some experience with “large” scale production
 - CMS/ATLAS pixels, LHCb VELO
 - More radiation hard than p-in-n



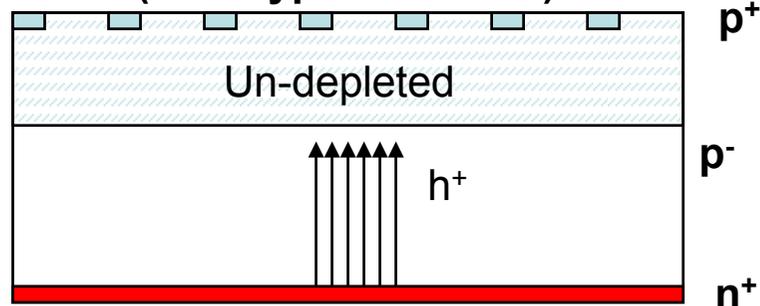
P-strip vs. N-strip Readout

Effect of trapping on the Charge Collection Efficiency (CCE)

$$Q_{tc} \cong Q_0 \exp(-t_c/\tau_{tr}), \quad 1/\tau_{tr} = \beta\Phi.$$

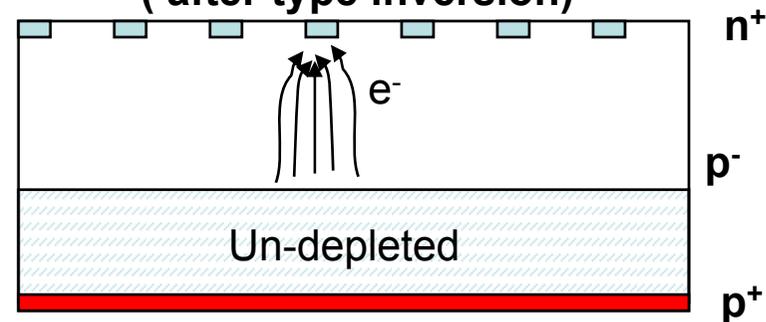
t_c is collection “time”, τ_{tr} is effective trapping time

“Standard” p-in-n geometry
(after type inversion)



“New” n-in-p geometry

“New” n-in-n geometry
(after type inversion)

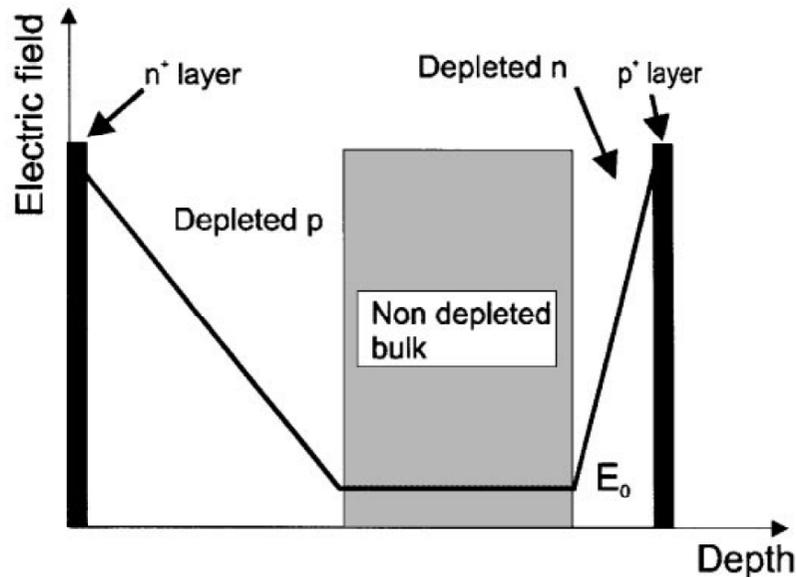


Type inversion turns lightly doped material to “p” type

- Holes collected
- Deposited charge cannot reach electrode
 - Charge spread over many strips
 - Lower signal

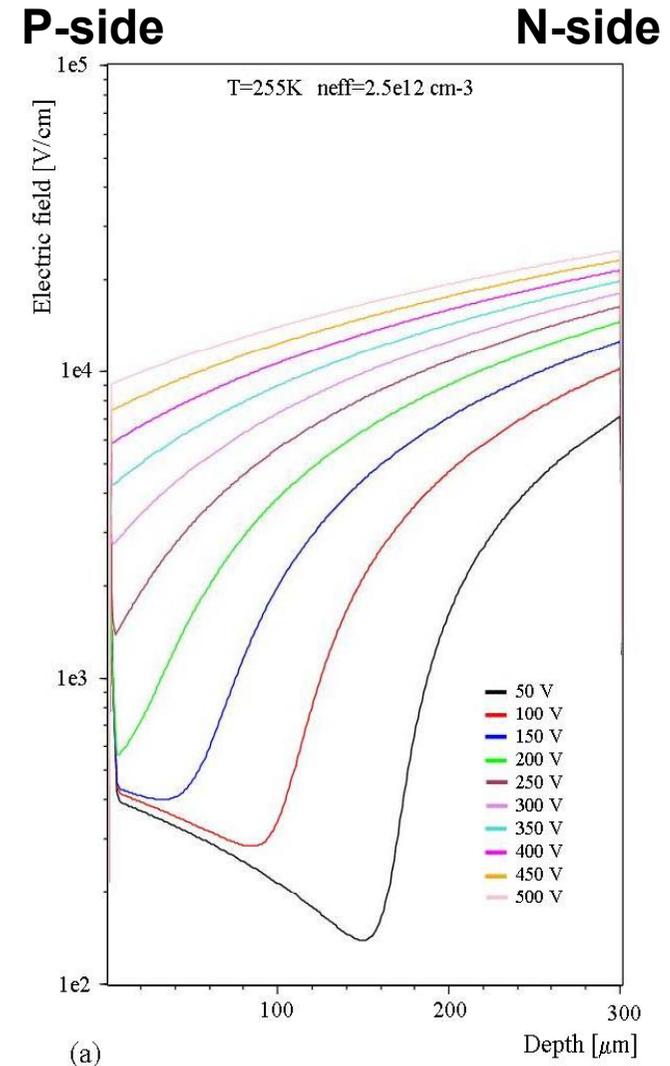
- Electron collected
 - Higher mobility and ~33% smaller trapping constant
- Deposited charge can reach electrode

Double Junction



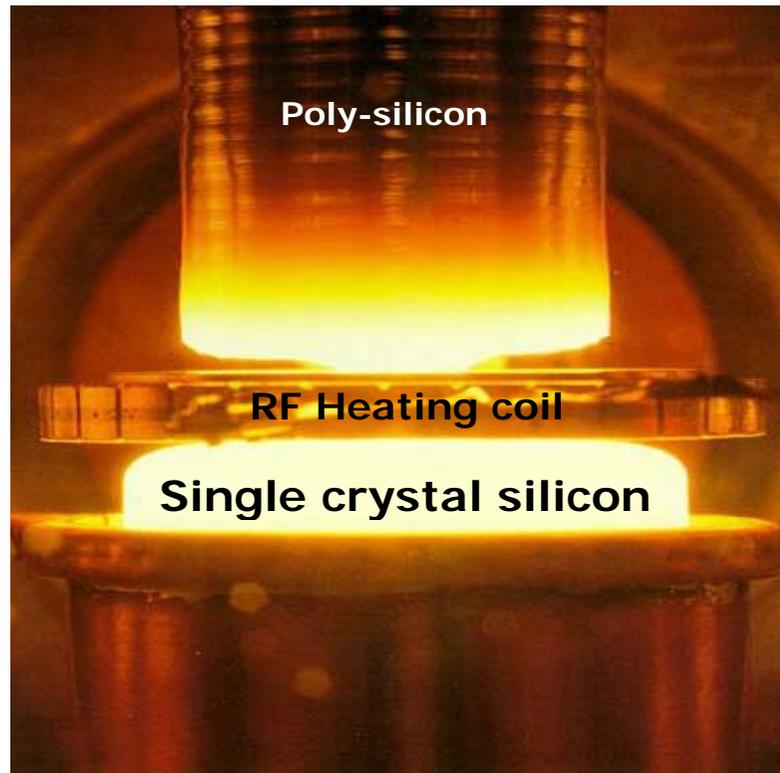
In reality, after irradiation electric fields show a double junction structure with a non-depleted bulk in the middle of the sensor below the full depletion voltage

See G. Casse, et. al., NIMA **426** (1999) 140-146 and G. Kramberger, et. al., NIMA **579** (2007) 762-765 for details

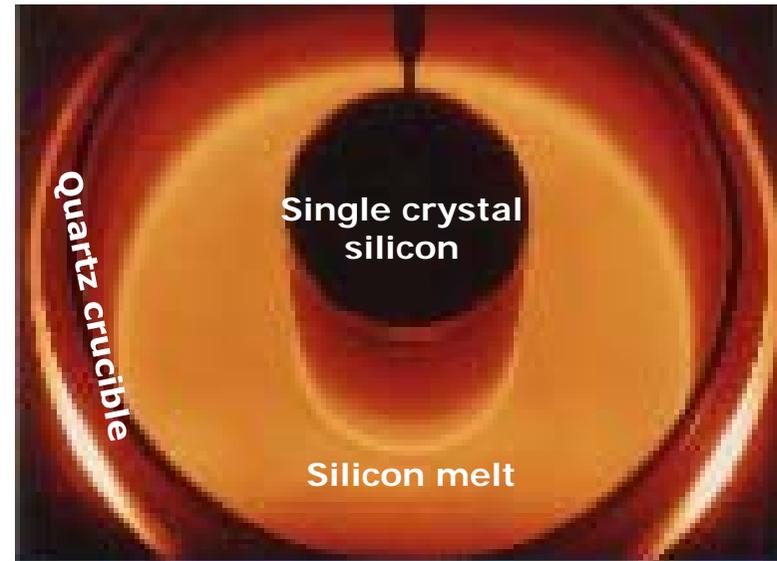


ISE-TCAD simulation after $6 \times 10^{14} \text{ p cm}^{-2}$

Wafer Technology Choices



- Float Zone (FZ)
 - Most experience
 - Relatively low initial V_{FD} (20-150V)



- Magnetic Czochralski(MCz)
 - More oxygen
 - More rad. hard??
 - Less uniformity in resistivity within wafer??
 - Less expensive??
 - Higher initial V_{FD} (150-700 V)

Miniature Silicon Micro-strip Sensors

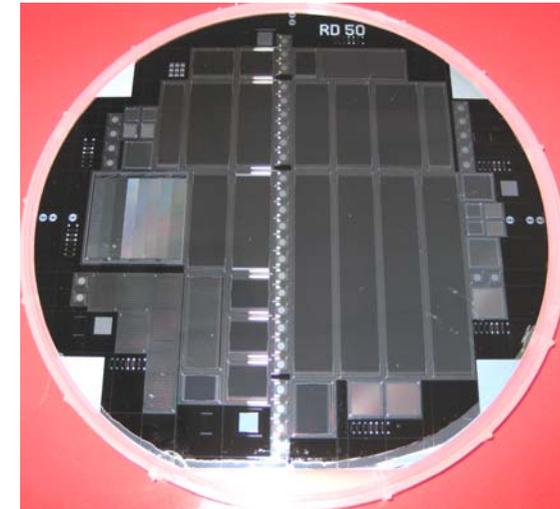
Micron/RD50 (6" wafers)

RD50 mask (see: <http://rd50.web.cern.ch/rd50/>)

Microstrip, $\sim 1 \times 1 \text{ cm}^2$, 128 strips, $80 \mu\text{m}$ pitch, $\leq 300 \mu\text{m}$ thickness

- n-in-p FZ ($V_{\text{FD}} \sim 100 \text{ V}$)
- n-in-p MCz ($V_{\text{FD}} \sim 550 \text{ V}$)
- n-in-n FZ ($V_{\text{FD}} \sim 70 \text{ V}$)
- n-in-n MCz ($V_{\text{FD}} \sim 170 \text{ V}$)
- p-in-n FZ ($V_{\text{FD}} \sim 70 \text{ V}$)
- p-in-n MCz ($V_{\text{FD}} \sim 170 \text{ V}$)

6 in.



Irradiation and dosimetry (Neutrons):
Jozef Stefan Institute, Ljubljana, Slovenia: **V. Cindro, et. al.**

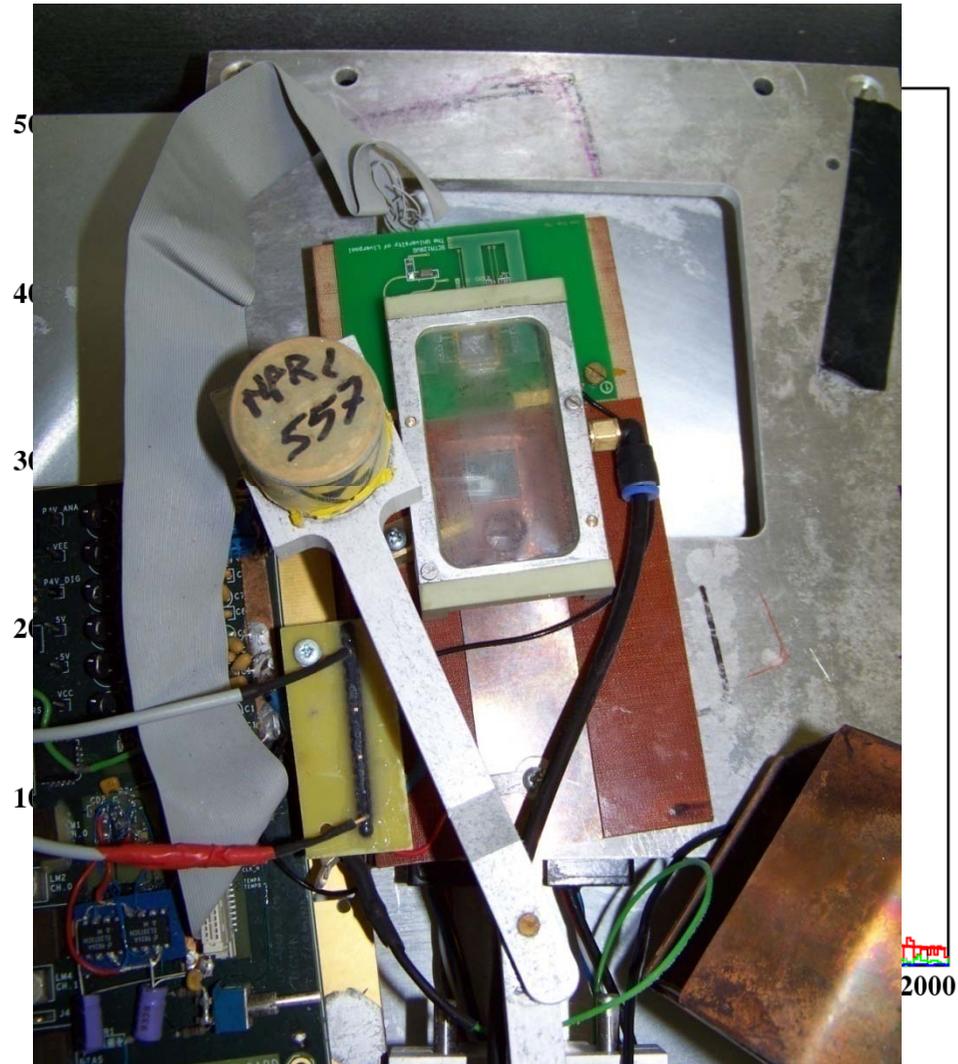
Irradiation and dosimetry (24 GeV Protons):
CERN PS Irrad1 facility: **M. Glaser, et. al.**

Irradiation and dosimetry (26 MeV Protons):
Karlsruhe: **W. de Boer, et. al.**

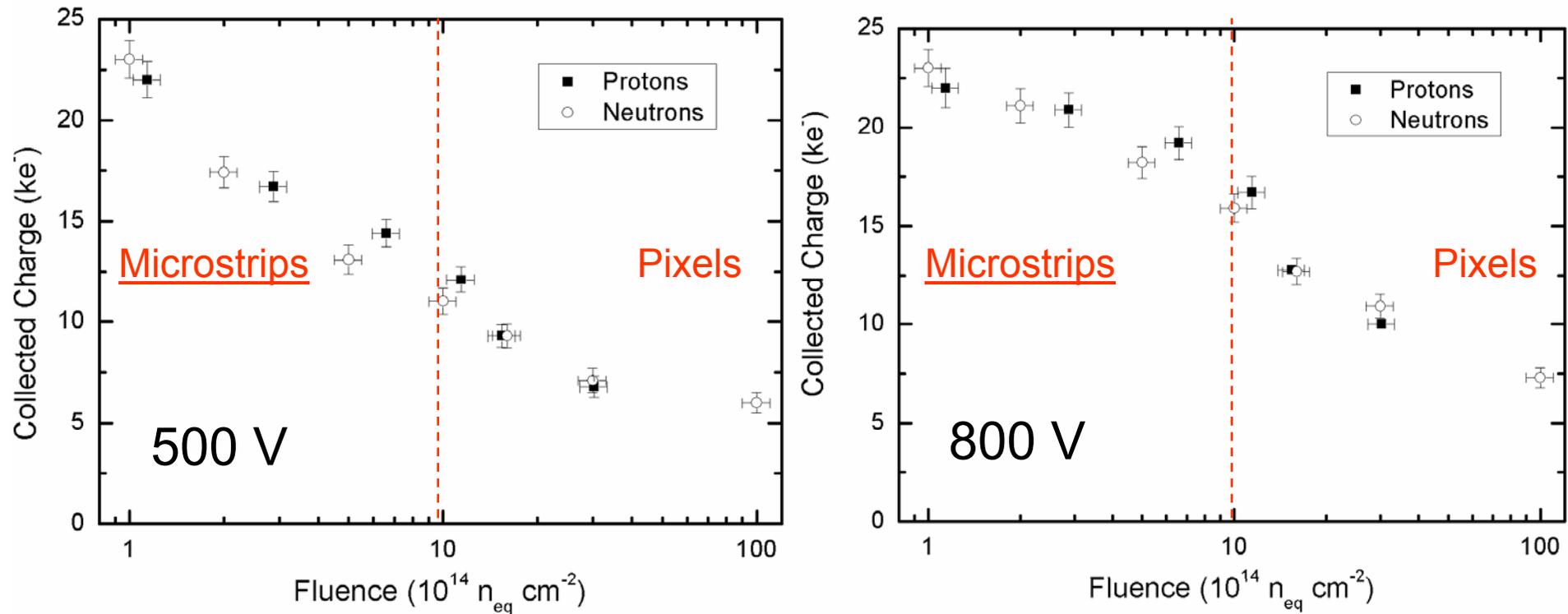
Most of this work has been performed using material and detectors produced within the framework of RD50.

Experimental Setup

- Charge collection efficiency (CCE) measured using detachable read-out analogue electronics chip (SCT128) clocked at LHC speed (40MHz clock, 25ns shaping time).
 - Measurements performed at a temperature down to $-25\text{ }^{\circ}\text{C}$ with N_2 flush
- ^{90}Sr fast electron source triggered with scintillators in coincidence used to generate signal.
- The system is calibrated to the most probable value of the MIP energy loss in a non-irradiated $300\mu\text{m}$ thick detector ($\sim 23000\text{ e}^-$).



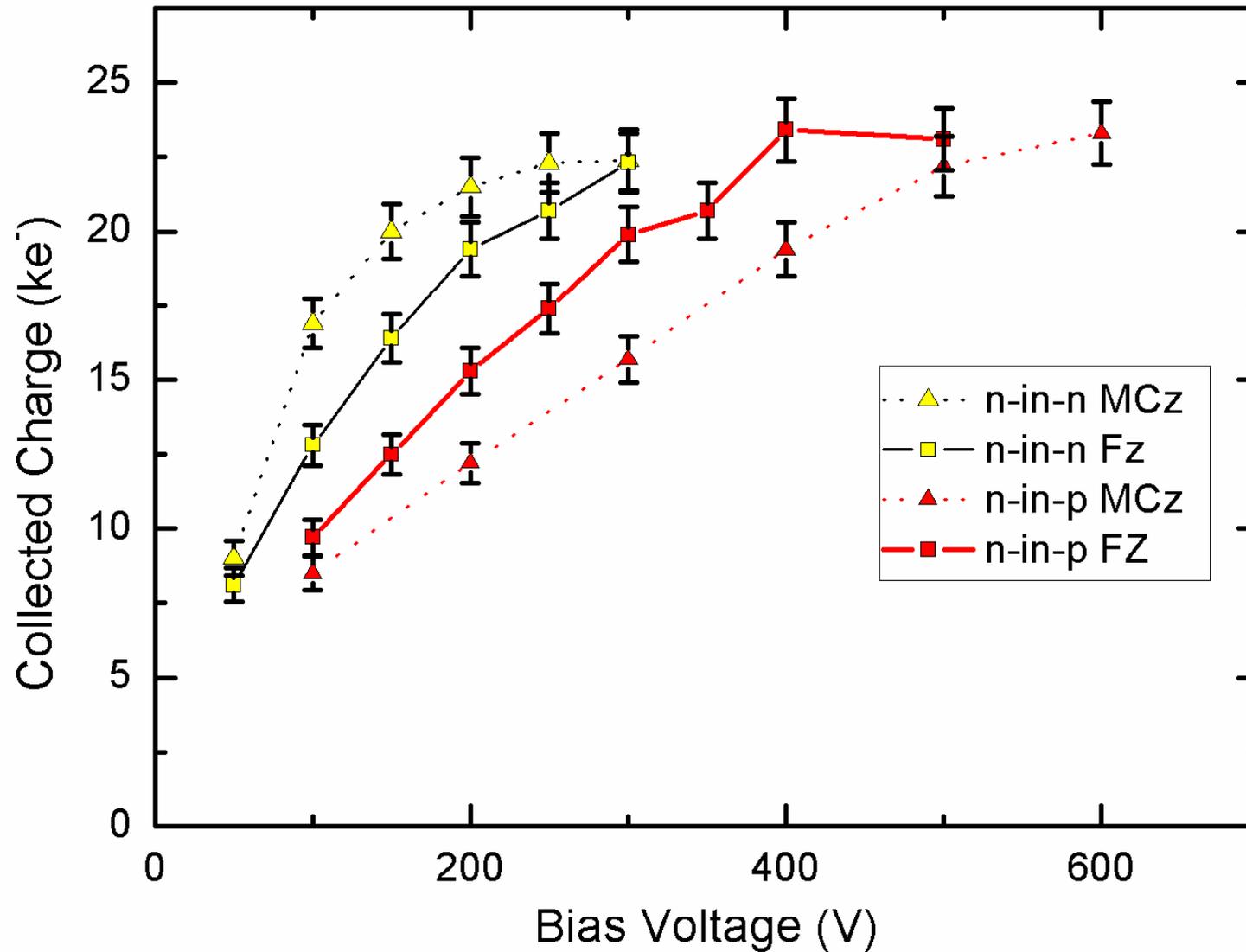
Liverpool Charge Collection Studies



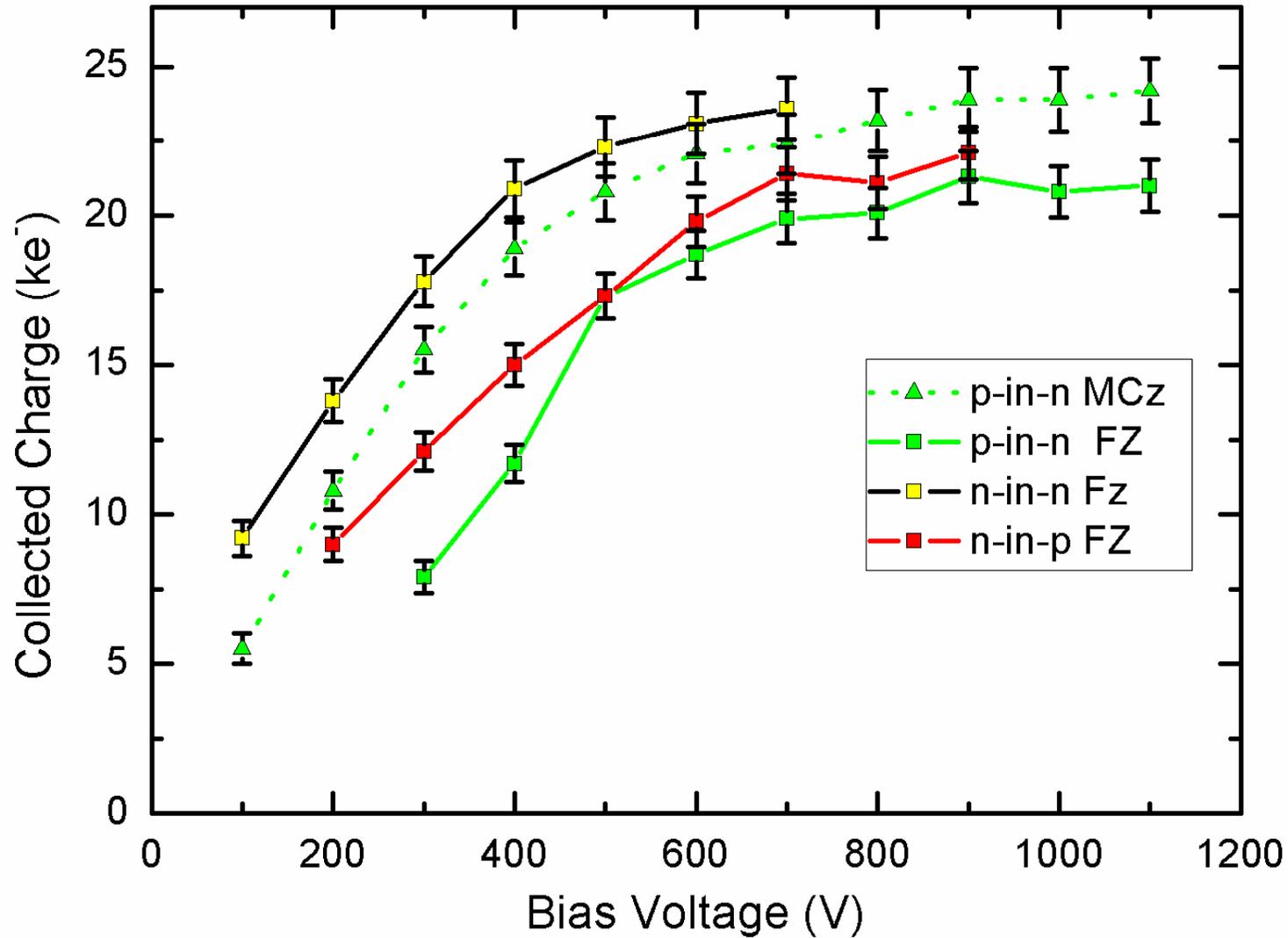
n-in-p FZ planar technology candidate for all layers
Higher doses ($>1 \times 10^{16}$ n_{eq} cm⁻²) to be reported soon

n-in-p, n-in-n, p-in-n FZ & MCz comparisons for microstrip doses to follow:

$1 \times 10^{14} \text{ n cm}^{-2}$

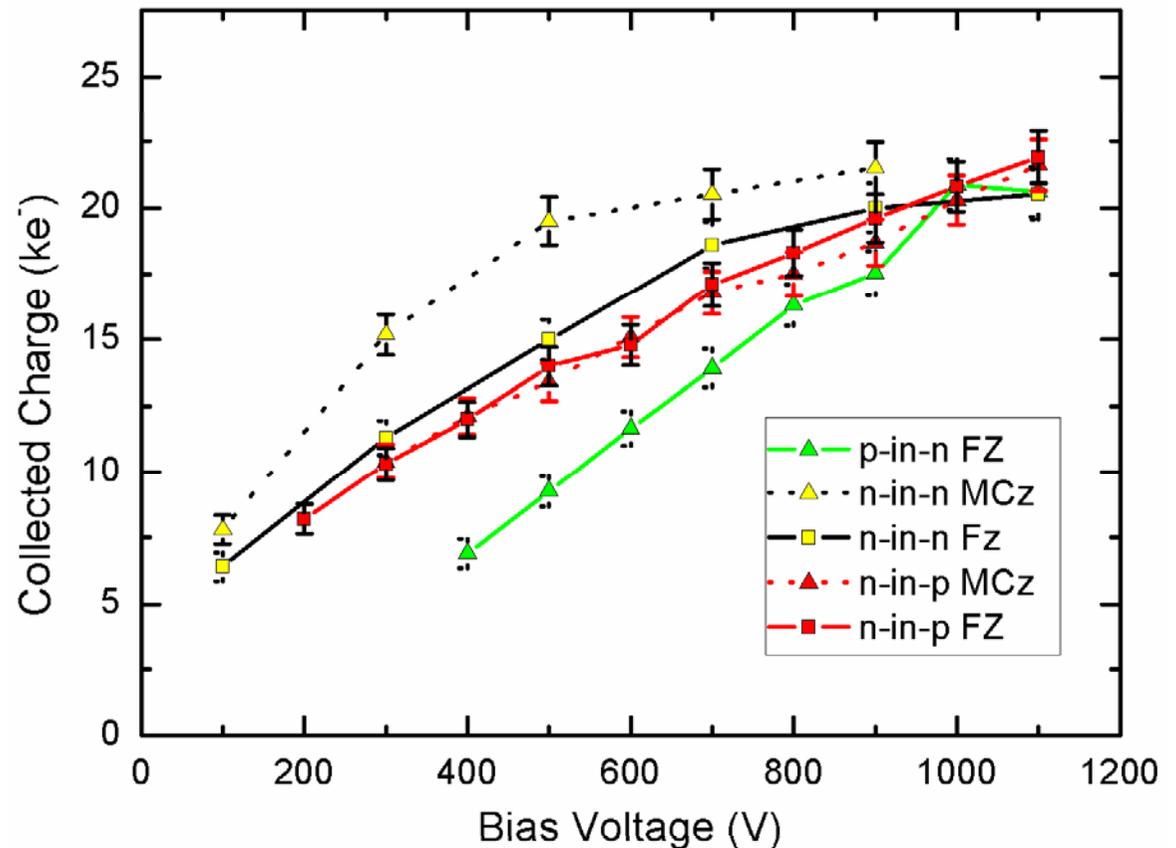


$2 \times 10^{14} \text{ n cm}^{-2}$



$5 \times 10^{14} \text{ n cm}^{-2}$

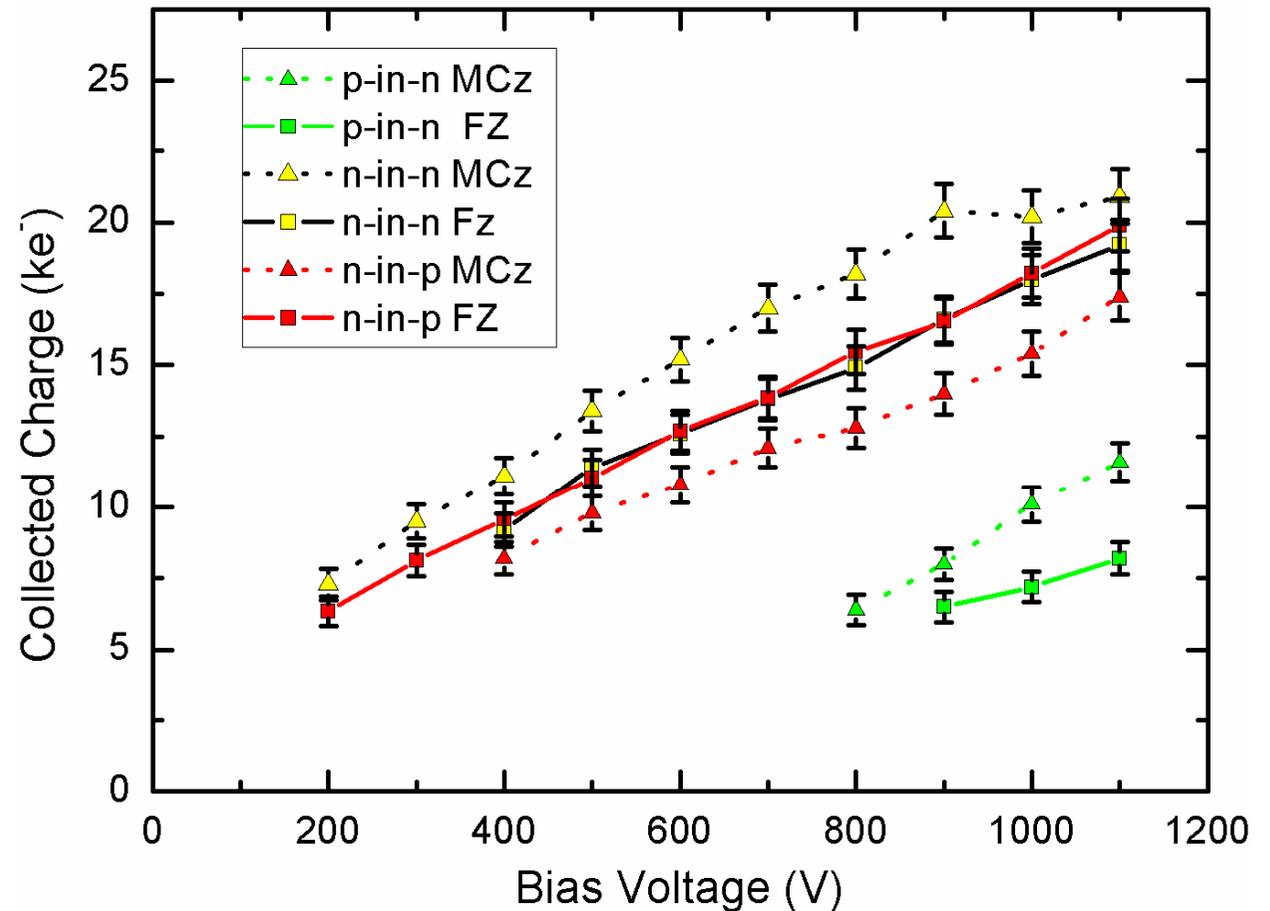
- Design flux for long (9 cm) strips
 - R=70-100 cm
 - Includes 2× safety factor
- p-in-n FZ extremely marginal CCE@500 V
- n-in-n and n-in-p show sufficient CCE@500 V for efficiency tracking (S:N >10:1)
 - Expected noise: ~1300 enc
 - Can be reduced to ~950 enc with 20% increase in chip power



Only n-in-n MCz significantly better

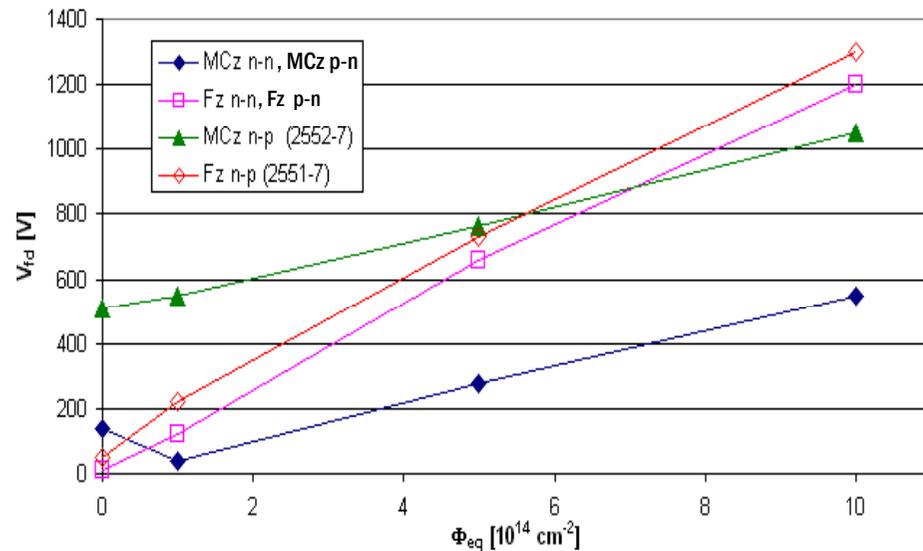
$1 \times 10^{15} \text{ n cm}^{-2}$

- Design flux for short (2.5 cm) strips
 - R=40-60 cm
 - Includes 2× safety factor
- n-in-n and n-in-p show sufficient CCE at 500 V for efficiency tracking (S:N >10:1)
 - Expected noise: 750 enc

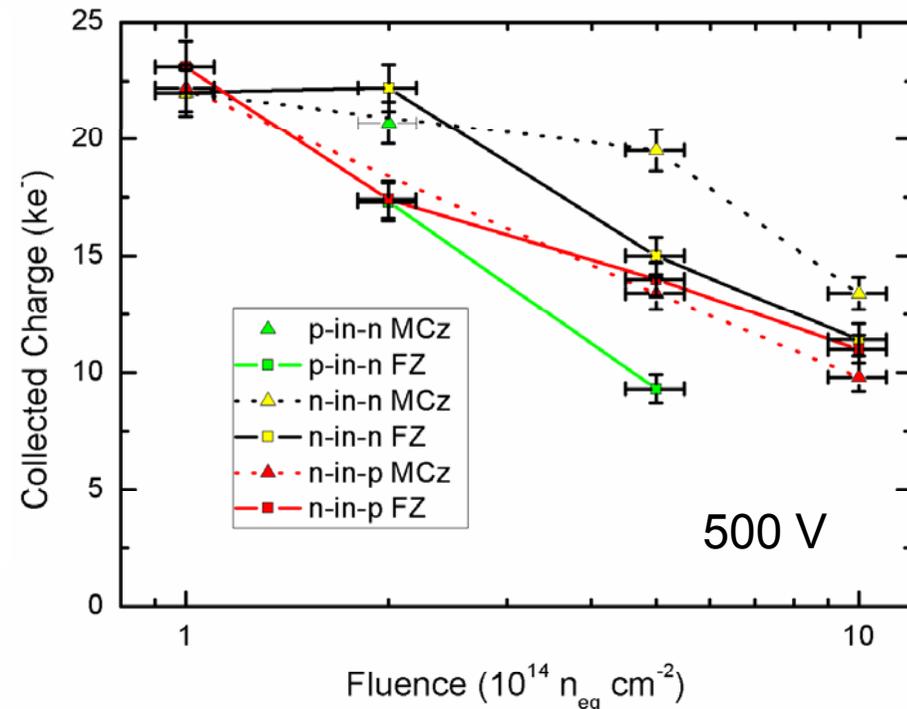


Only n-in-n MCz significantly better

Neutron Summary

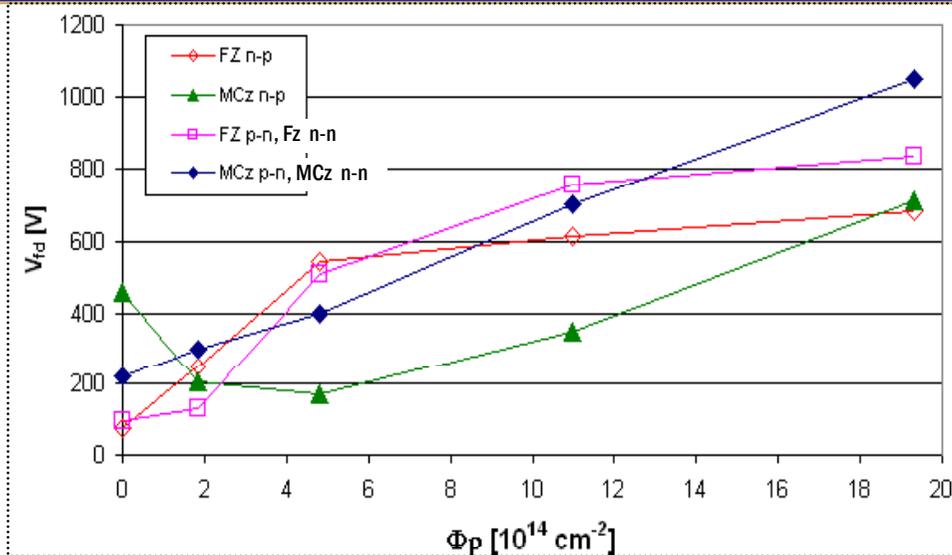


G. Kramberger, "Charge collection measurements on MICRON RD50 detectors", ATLAS Tracker Upgrade Workshop, Valencia 11-14 December 2007, <http://ific.uv.es/slhc/ATLASUpgrade/>

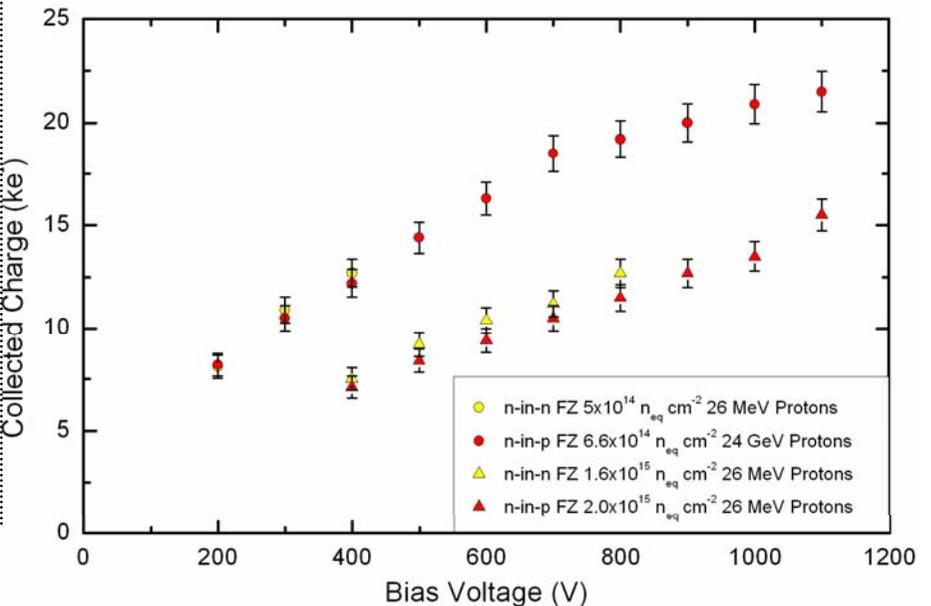


- Both p-in-n FZ and p-in-n MCz sensors show insufficient charge collection for short strip regions ($>5 \times 10^{14} \text{ n}_{eq} \text{ cm}^{-2}$)
- n-in-n FZ, n-in-p FZ, and n-in-p MCz similar in terms of CCE at these doses
 - n-in-n FZ slightly better at doses $< 5 \times 10^{14} \text{ n}_{eq} \text{ cm}^{-2}$
- n-in-n MCz shows best performance as expected from CV measurements

Proton Irradiations

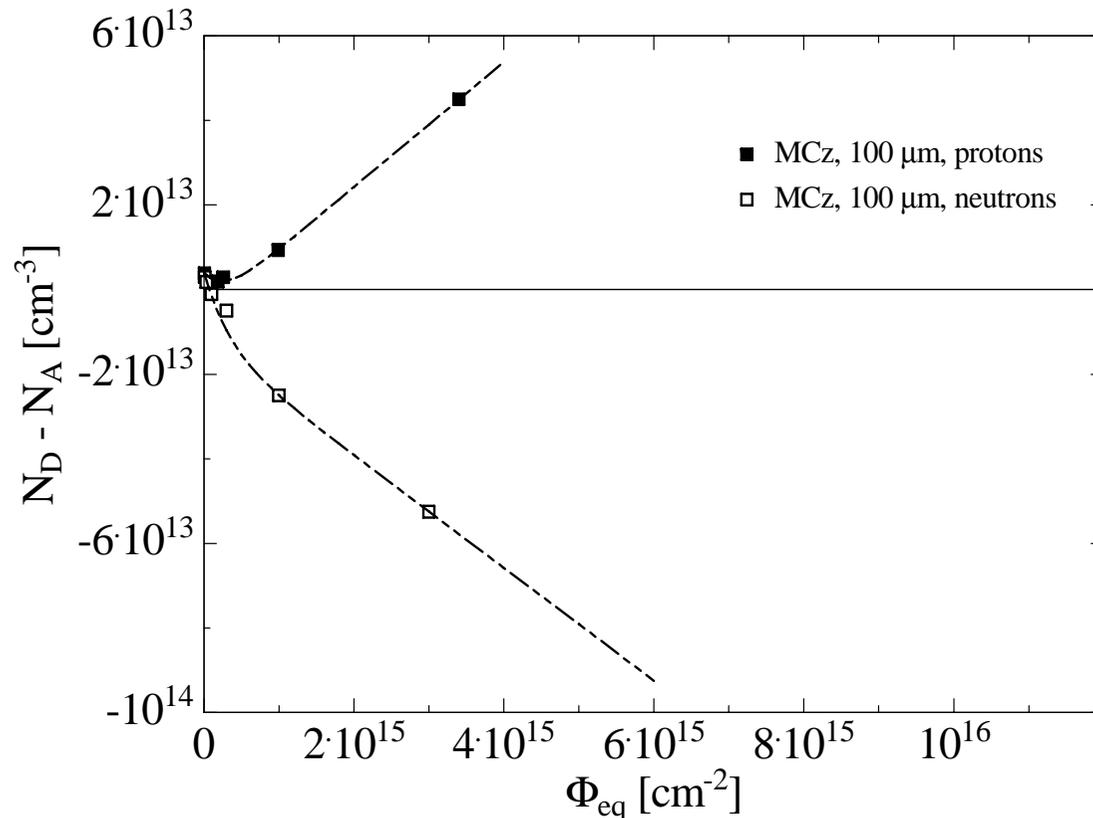


G. Kramerberger, et.al., 3rd Workshop on Advanced Silicon Radiation Detectors (3D and P-type Technologies), Barcelona 14-16 April 2008, <http://indico.cern.ch/conferenceDisplay.py?confId=28165>



- At the proposed inner radii of the short strips, charged particles are ~50% of flux
 - V_{FD} measurement with proton irradiation shows significant differences from neutron irradiations
- **CCE measurements after pion and more for proton irradiation needed**
- As of now, we only have n-in-n FZ and n-in-p FZ results available
 - Both show similar CCE
- More n-in-p MCz and n-in-n MCz wafer currently in process
 - New results available in 2009

Mixed Irradiations (MCz)



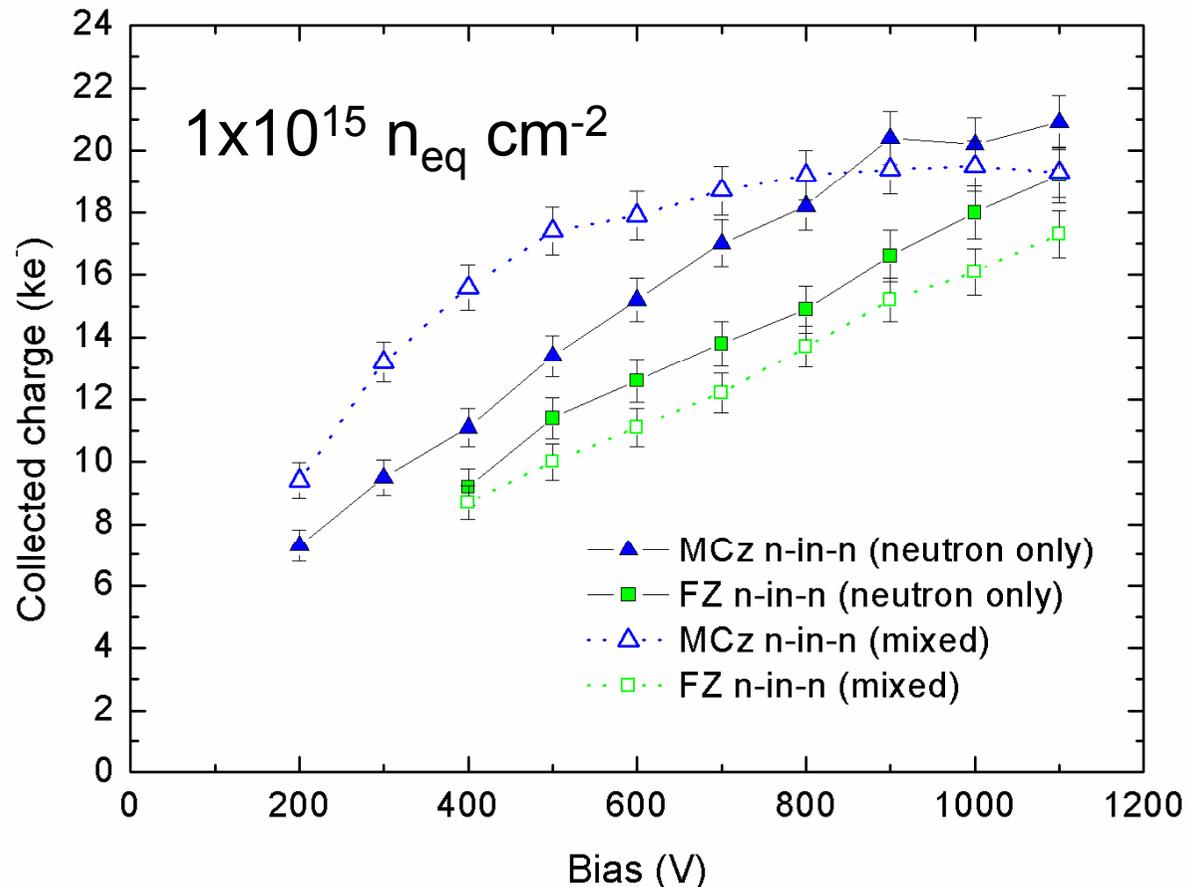
E. Fretwurst et al., 11th RD50 workshop

Practical outcome:
possible partial
compensation of N_{eff} ,
therefore better CCE
at low voltages?

- $\beta > 0$ (dominant donor creation) for protons (more point defects than clusters)
- $\beta < 0$ (dominant acceptor creation) for neutrons (more clusters than point defects)

Mixed Irradiations (Neutrons+Protons)

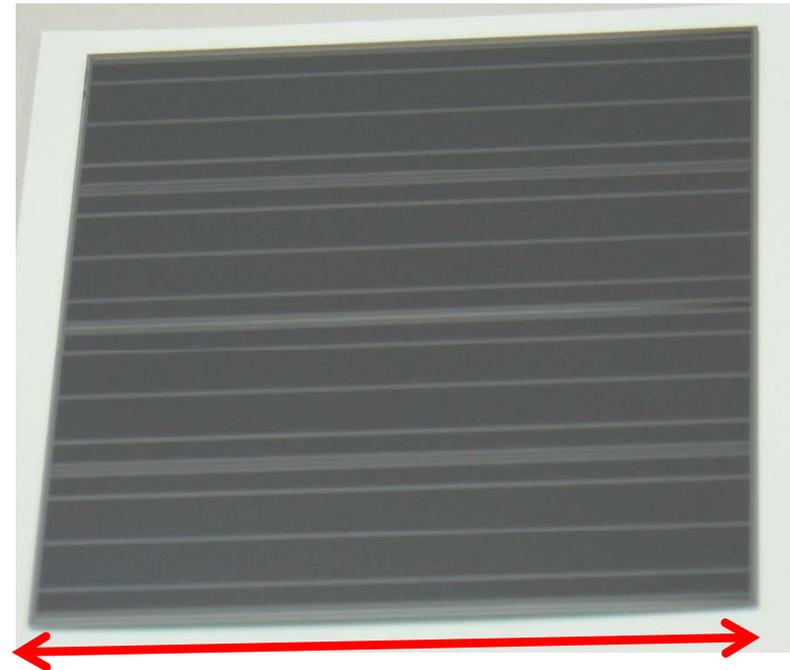
- Both FZ and MCz show “predicted” behaviour with mixed irradiation
 - FZ doses add
 - $|N_{\text{eff}}|$ increases
 - MCz doses compensate
 - $|N_{\text{eff}}|$ decreases



Needs further study with both nMCz and pMCz substrates and differing mixed doses

Conclusions

- The SLHC upgrade is planned for 2015
 - Current p-in-n technology used unable to cope with expected fluences
- Both n-in-p and n-in-n geometries in both FZ/MCz materials have sufficient radiation hardness
 - **n-in-n MCZ had best results**
- FZ n-in-p (single-sided) chosen technology for short and long strip regions for ATLAS upgrade
 - Cost and availability of high production capacity: Hamamatsu (HPK)
 - Full-size HPK prototypes already in hand



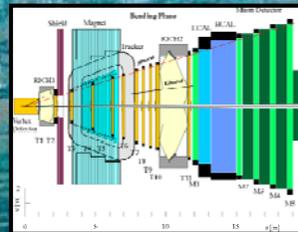
10 cm × 10 cm

- All geometries should be studied further for smaller, highly irradiated, inner regions

CERN Large Hadron Collider

- Proton on proton collisions: $\sqrt{s} = 14 \text{ TeV}$
 - Highest Energy Collider Ever
 - 25 ns between beam crossings
 - Peak Luminosity $10^{34} \text{ cm}^{-2} \text{ s}^{-1}$
 - 20 minimum bias collisions per beam crossing
- First Beams September 2008!!!

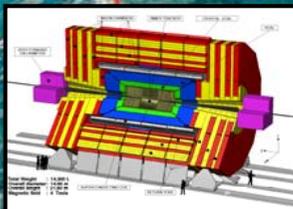
LHCb



ATLAS



CMS



Alice

